

Application/Control No.	Applicant(s)/Patent under Reexamination		
10/042,780	VANDENAMEELE-LEPLA, PATRICK		
Examiner	Art Unit		
Linda Wong	2634		

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Class	Subclass	Date	Examiner
342	13	4/28/2005	LW
375	371	4/28/2005	LW
370	210	4/28/2005	LW
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Class	Subclass	Date	Examiner
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SEARCH NOTES (INCLUDING SEARCH STRATEGY)				
	DATE	EXMR		
EAST	4/28/2005	LW		
Inventor's Search	4/29/2005	LW		
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